

## Transaction Information

Tool ID	DFRN716
Tool Status	Running Wafers
Location	Singapore
Wafer Size	300 mm
Fab Section	Diffusion
Tool Available Date	2025-03-31

## General Product Information

Vendor Supplier	TEL
Model	TEL FORMULA-1S-H
Vintage	2008
Serial No	P000008X5073
Asset Description	LPCVD Nitride with In-situ clean furnace
Software Version	V2.12 Rev.R010 [F00B00-0000F]
CIM	SECS
Process	LPCVD Nitride with In-situ clean

## Hardware Configuration

System Type	Description	Quantity	Status
Factory Interface	FOUP	2	OK
Options System	RCU	1	OK
Others	Gas detector	1	OK
Main System	TEL Formula Nitride furnace	1	OK
Handler System	TEL Formula Robot		OK
Others	Power Box		OK

## Excluded Items List (Pumps, Chillers & Abatement are all excluded)

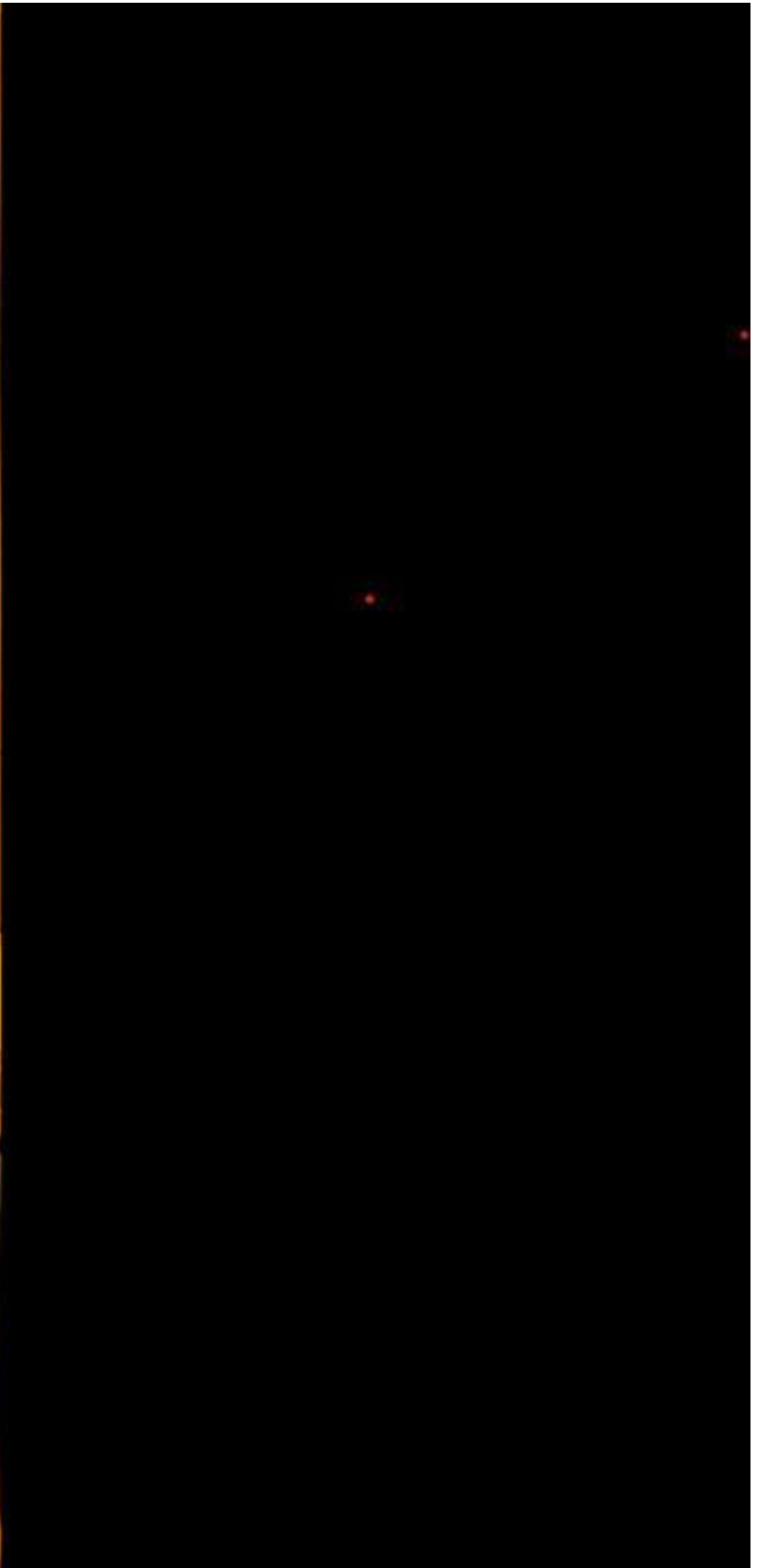
Description	Quantity
Nil	

\* List above may or may not be comprehensive. Tool is sold in "as-is" condition. To ensure your satisfaction, we strongly recommend to make an appointment to inspect this and every tool you are interested in.

# Tool Pictures

General

TEL Formula





Hardware Fab

Main body





Hardware Sub-fab

Related







Manufacture Serial

P000008X5073

